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Cite this: *RSC Adv.*, 2016, 6, 50250

Received 7th April 2016
Accepted 4th May 2016

DOI: 10.1039/c6ra09011g

www.rsc.org/advances

Trifluoromethylation of haloarenes with a new trifluoro-methylating reagent $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2^\ddagger$

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A new trifluoromethylating reagent $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$, which easily decomposes to generate active CuCF_3 species in DMF at room temperature, has been conveniently prepared from inexpensive starting materials on a large scale. This new reagent can be applied to efficiently trifluoromethylate a variety of haloarenes under mild conditions, providing good-to-excellent yields of the desired products.

1. Introduction

Trifluoromethyl-containing aromatic compounds are becoming increasingly important as privileged structural motifs in pharmaceuticals, agrochemicals and drug candidates due to the unique properties arising from the electron-withdrawing nature, unique lipophilicity and metabolic stability of the trifluoromethyl groups.¹ Hence, considerable effort has been made to synthesise them and considerable progress has been achieved in recent decades.² Representative aromatic trifluoromethylation during the last few decades includes transition-metal-promoted nucleophilic trifluoromethylation^{2a-d,g-j} as well as radical trifluoromethylation.^{2e,fi} Among these methodologies, copper-mediated aromatic trifluoromethylation has been most extensively studied and applied^{2,3} due to its good reactivity, relatively low cost of copper and good regioselectivity.⁴ Various CuCF_3 reagents preformed or generated *in situ* from a variety of CF_3 sources have been developed recently and demonstrated good reactivity towards haloarenes or their analogues.² For example, Vicic,⁵ Hartwig,⁶ Grushin⁷ and Weng⁸ successively reported relatively stable and well defined complexes of $(\text{L})_n\text{CuCF}_3$ based on Me_3SiCF_3 by treatment with a Cu(I) salt and an appropriate ligand. Grushin's group subsequently developed the first reaction of direct cupration of fluoroform by treatment with CuCl and KO^tBu followed by stabilization with $\text{Et}_3\text{N} \cdot 3\text{HF}$ to generate highly active CuCF_3 reagents.⁹ Hu¹⁰ and Mikami¹¹ independently reported the preparation of CuCF_3 reagent from cuprate and phenyl trifluoromethyl sulfones and trifluoromethyl ketone derivatives, respectively. Xiao found that difluorocarbene derived from various carbene precursors could be decomposed by DBU (1,8-diazabicyclo[5.4.0]undec-7-ene) to generate a fluoride ion and further converted to CuCF_3 in the

presence of a Cu(I) salt to efficiently finish trifluoromethylation with iodoarenes.¹² Zhang reported a new reagent trimethylsilyl chlorodifluoroacetate for the efficient synthesis of trifluoromethyl-substituted arenes.¹³ Very recently, Weng reported the synthesis and trifluoromethylation reactions of a decarboxylative trifluoromethylating reagent $(\text{phen})\text{Cu}(\text{O}_2\text{CCF}_3)$ ($\text{phen} = 1,10\text{-phenanthroline}$).¹⁴ Despite these notable accomplishments, it is still desirable to develop efficient and convenient reagents to access various trifluoromethylated arenes under mild conditions.

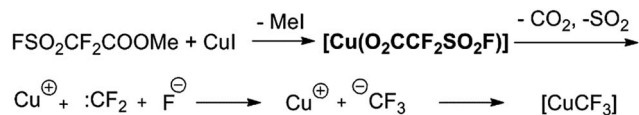
Because of our long-standing interest in various trifluoromethylation reactions, we have always been turning our attention and putting effort toward developing new trifluoromethylation methods, particularly by using tetrafluoroethene β -sultone-based fluorinating derivatives as reagents.¹⁵ Tetrafluoroethylene β -sultone is a unique cyclic compound and can be conveniently synthesized from the reaction between cheap $\text{CF}_2=\text{CF}_2$ and SO_3 in nearly quantitative yield.¹⁶ Dupont commercialized perfluorinated Nafion polymer (NafionTM), a key source of pendant perfluoroalkylsulfonate groups, which has been widely manufactured and used as a basic and important industrial product.¹⁷ Hence, fluorinating reagents derived from it are inexpensive and readily available in large quantities. In 1989, to the best of our knowledge, we developed the first catalytic trifluoromethylation reaction of haloarenes with $\text{FSO}_2\text{CF}_2\text{COOMe}$ (ref. 17) in DMF at 60–80 °C in the presence of catalytic amounts of CuI, leading to various trifluoromethylated arenes in good yields.^{3h} Later on, several related trifluoromethylating reagents were developed to efficiently furnish a variety of desired trifluoromethylated arenes.¹⁵ It has been proposed that the reaction pathway involves the formation of the corresponding $\text{Cu}(\text{I})(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})$ as the intermediate, followed by decarboxylation and generation of difluorocarbene, which in combination with a fluoride ion produces a CF_3Cu species in the presence of Cu(I) (Scheme 1).^{3h,15} However, this $\text{Cu}(\text{I})(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})$ has not been isolated or detected spectroscopically in the reaction system. We then sought to isolate and characterize the intermediate $\text{Cu}(\text{I})(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})$. During the study, it was

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[†] Electronic supplementary information (ESI) available. CCDC 1450534. For ESI and crystallographic data in CIF or other electronic format see DOI: 10.1039/c6ra09011g

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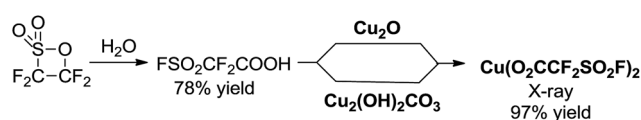
Scheme 1 Proposed decomposition mechanism of FSO₂CF₂COOMe in the presence of CuI in the literature.

found that fluorosulfonyldifluoroacetic acid copper(II) salt Cu(II)(FSO₂CF₂COO)₂,¹⁹ instead of Cu(I)(O₂CCF₂SO₂F), was easily prepared in a large quantity and could be used as an efficient and mild trifluoromethylating agent. Herein, we present the results.

2. Results and discussion

At the beginning, we became aware of the potential to synthesize and isolate the key intermediate Cu(I)(O₂CCF₂SO₂F) as a new trifluoromethylating reagent. Attempts were carried out to prepare it by mixing FSO₂CF₂COOH (ref. 18) with excess amounts of the corresponding Cu₂O in Et₂O. The color of the contents turned to dark-blue after stirring for 24 hours at room temperature. After filtration and evaporation of the solvent Et₂O and water generated during the reaction, a blue powder was obtained (Scheme 2). To our surprise, it was not the desired Cu(I)(O₂CCF₂SO₂F) but Cu(II)(O₂CCF₂SO₂F)₂ after thorough characterization by ¹⁹F NMR spectroscopy, elemental analysis and X-ray structural analysis. The redox processes involved in the reaction was unclear at this stage. The ¹⁹F NMR spectrum shows a typical paramagnetic resonance due to the Cu(II) center. The single crystals obtained by solvent diffusion (Et₂O/hexane) were subjected to X-ray structural analysis. The copper(II) center is bound by two fluorosulfonyldifluoroacetic ions and four water molecules as ligands and demonstrates an axially-elongated octahedron configuration. As expected, the reaction of FSO₂CF₂COOH and a copper(II) salt Cu₂(OH)₂CO₃ under similar conditions afforded the corresponding Cu(O₂CCF₂SO₂F)₂ in almost quantitative yield. The reaction was run on a >50 gram scale, and the procedure was very simple. Both starting materials are commercially available and inexpensive. As such, Cu(O₂CCF₂SO₂F)₂ is very convenient to prepare on a large scale.

Cu(O₂CCF₂SO₂F)₂ is a stable and hygroscopic blue powder. No obvious decomposition occurred after storage for more than one month at 4 °C under dry air, and it displayed reactivity similar to that of a freshly prepared material. It is relatively stable in low polarity solvents such as CH₂Cl₂, acetone, toluene, THF and Et₂O at room temperature. However, it decomposes quickly in highly polar solvents such as CH₃CN, MeOH, DMF and DMSO at room temperature. Notably, it is highly soluble in

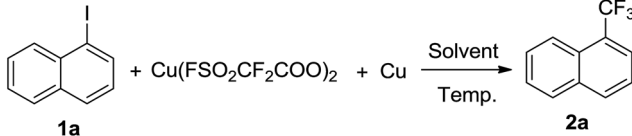


Scheme 2 Preparation of Cu(O₂CCF₂SO₂F)₂.

Et₂O and THF, which is beneficial for the work-up. To our delight, both [Cu(CF₃)] (δ = −26.6 ppm) and [Cu(CF₃)₂[−]] (δ = −31.3 ppm) species were detected in the reaction solution of Cu(O₂CCF₂SO₂F)₂ in DMF according to the ¹⁹F NMR spectra, which matched well with the previous reported results.^{3f,9,20}

To assess the potential of Cu(O₂CCF₂SO₂F)₂ as a trifluoromethylation reagent, its reactivity with 1-iodonaphthalene (**1a**) was investigated under various conditions. As shown in Table 1, treatment of **1a** with 1.5 equivalent of Cu(O₂CCF₂SO₂F)₂ in DMF at room temperature for 3 hours resulted in smooth formation of the desired 1-trifluoromethylnaphthalene (**2a**) in 50% yield. As the Cu(I)CF₃ species is widely considered to be the real active intermediate, we attempted to convert Cu(II) to Cu(I) by adding an equal equivalent of Cu in the reaction system. To our delight, the reaction yield increased significantly to 96% in the presence of an equal equivalent of Cu. A survey of stoichiometry of Cu(O₂CCF₂SO₂F)₂/Cu and reaction temperatures showed that 1.5 equivalents and room temperature were the best choices. DMF stood out to be a more effective solvent than DMSO, DMAc, NMP and CH₃CN. It should be mentioned that in some cases 1-(pentafluoroethyl)naphthalene was observed as a side-product in trace amounts. The role of some additives was also investigated. KF, NEt₃ and DBU had no significant effect on the reaction. In addition, prolonging the reaction time to 12 hours was not beneficial. In brief, a combination of 1.5 equivalents of

Table 1 Optimization of trifluoromethylation reactions of Cu(O₂CF₂SO₂F)₂ with **2a** under various conditions^a



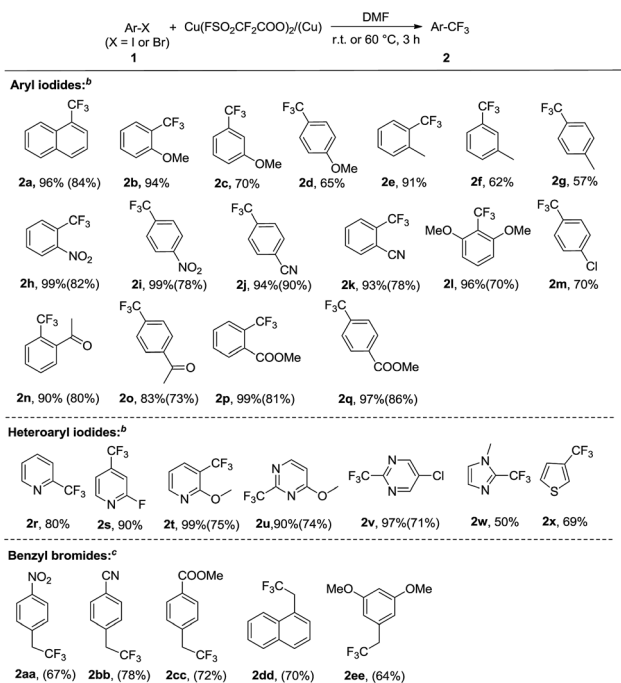
Entry	Solvent	Temp. (°C)	Additives	Yield ^b (2a)
1 ^c	DMF	25	— ^d	50%
2	DMF	25	— ^d	96%
3 ^e	DMF	25	— ^d	96%
4 ^f	DMF	25	— ^d	85%
5 ^g	DMF	25	— ^d	85%
6	DMF	0	— ^d	74%
7	DMF	−5	— ^d	68%
8	DMF	−10	— ^d	57%
9	DMF	−20	— ^d	30%
10	DMSO	25	— ^d	0
11	NMP	25	— ^d	82%
12	DMAc	25	— ^d	83%
13	CH ₃ CN	25	— ^d	0
14	DMF	25	KF	90%
15	DMF	25	Et ₃ N	96%
16	DMF	25	DBU	87%

^a Reaction conditions: 1-iodonaphthalene (0.2 mmol, 1.0 equiv.), Cu(FSO₂CF₂COO)₂ (0.3 mmol, 1.5 equiv.), Cu (0.3 mmol, 1.5 equiv.) in solvent (2 mL) under a nitrogen atmosphere for 3 hours at the reaction temperatures indicated above. ^b Yields were determined by ¹⁹F NMR with trifluorotoluene as an internal standard. ^c Without Cu. ^d No additive was used. ^e 2.5 equiv. of Cu(O₂CCF₂SO₂F)₂/Cu was used. ^f 1.0 equiv. of Cu(O₂CCF₂SO₂F)₂/Cu was used. ^g Reaction time: 12 hours.



$\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$ and Cu in DMF at room temperature for 3 hours was established as the optimal reaction conditions for the trifluoromethylation.

Under these optimal reaction conditions, the scope of iodoarenes was carefully examined. As shown in Scheme 3, a variety of aryl iodides could be subjected to trifluoromethylation under mild conditions, giving the corresponding trifluoromethylated products in good-to-excellent yields. In general, electron-deficient aryl iodides (**1h–k**, **1n–q**) demonstrated better reactivity and yields than electron-rich aryl iodides (**1b–g**). Remarkably, the enhanced reactivity of *ortho*-substituted haloarene substrates was observed (**1b**, **1e**, **1l**, **1n**, **1p**), which is consistent with the previously reported *ortho*-effect.^{9b,c} This *ortho*-effect is characteristic of copper-mediated aromatic substitution reactions in general. Moreover, ether, nitro, acetyl, halide, ester and nitrile were tolerated under the standard conditions. In addition, we explored the scope of the trifluoromethylation reaction by utilizing heteroaryl iodides. Iodopyridenes, iodopyrimidines, iodoimidazole and iodothiofuran (**1r–1x**) were all suitable substrates, resulting in the desired trifluoromethylated products in good yields. In addition, it should be noted that in many cases, the isolated yields of the desired trifluoromethylated products were much lower than what could be detected by NMR spectroscopy, which may be attributed to their high volatility or similar polarity to the starting iodoarenes.

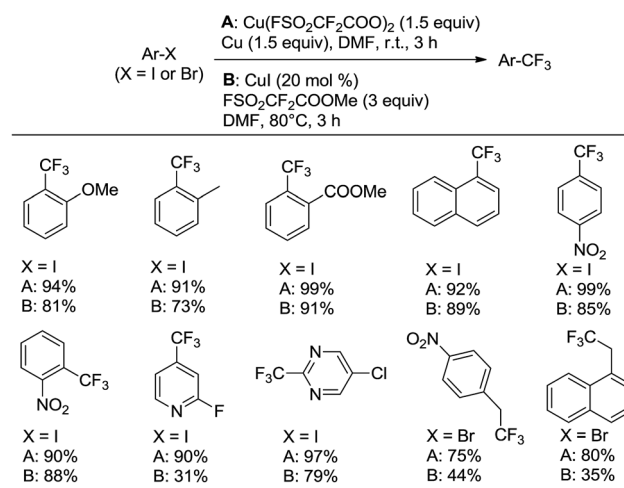


Scheme 3 Scope of the trifluoromethylation of various iodoarenes.^a ^aYields were determined by ¹⁹F NMR with trifluorotoluene or 4-(trifluoromethoxy)benzotrifluoride as the internal standard. Isolated yields are given in parentheses. ^bReaction conditions: substrate **1** (0.4 mmol, 1.0 equiv.), $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$ (0.6 mmol, 1.5 equiv.), Cu (0.6 mmol, 1.5 equiv.) in DMF (4 mL) under a nitrogen atmosphere at room temperature for 3 hours. ^cReaction conditions: substrate **1** (0.5 mmol, 1.0 equiv.), $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$ (1.0 mmol, 2 equiv.) in DMF (5 mL) under nitrogen atmosphere at 60 °C for 3 hours.

We next extended trifluoromethylation on various benzyl bromides under the abovementioned standard conditions. Although the reaction proceeded smoothly and successfully produced the desired product, the yield was not good (<30%). After further screening of the reaction conditions, it was found that the trifluoromethylation reactions of benzyl bromides proceeded better without the use of copper and at higher reaction temperatures (60 °C). Various benzyl bromides (Scheme 3, **1aa–ee**) were efficiently and conveniently subjected to smooth trifluoromethylation under these conditions, providing the desired products in good yields (Scheme 3).

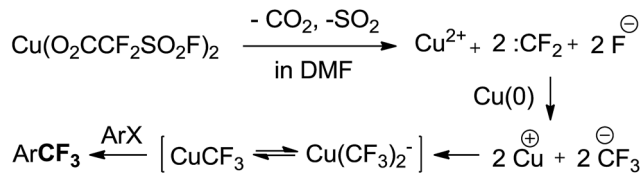
Subsequently, a comparison of the reactivity of the new trifluoromethylating reagent $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$ with our previously reported trifluoromethylating reagent $\text{FSO}_2\text{CF}_2\text{COOMe}$ (ref. 3h and 18) with various haloarenes was performed (Scheme 4). The results clearly suggest that $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$ demonstrates higher reactivity and better yields than $\text{FSO}_2\text{CF}_2\text{COOMe}$.

To determine the mechanism of trifluoromethylation with $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$, we first carefully examined the decomposition of $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$ in DMF using ¹⁹F NMR analysis (see the ESI[†]). A singlet peak at −31.3 ppm assigned to $[\text{Cu}(\text{CF}_3)_2]^-$ was detected in 10 minutes. One hour later, a broad singlet peak at −26.5 ppm, which is considered to be the reactive mono- CuCF_3 species according to the literature,^{3f,9,20} appeared and the intensity of the signal at −31.3 ppm decreased. Two hours later, the singlet at −26.5 ppm further increased, whereas the signal at −31.3 ppm further decreased. Based on these experimental results and the literature, we proposed a plausible mechanism (Scheme 5). First, $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$ in DMF decomposes into Cu^{2+} , $:\text{CF}_2$ and fluoride with the release of SO_2 and CO_2 . Then, difluorocarbene and fluoride combine into a CuCF_3 species in the presence of Cu^{2+} and Cu. CuCF_3 generated *in situ* reacts with the haloarenes to provide the desired trifluoromethylated products. It should be mentioned that CuCF_3 generated in our reaction system is a 'ligandless' species according to the



Scheme 4 Comparison of trifluoromethylating reagent $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$ with $\text{FSO}_2\text{CF}_2\text{COOMe}$ on various haloarenes. Yields were determined by ¹⁹F NMR with trifluorotoluene or 4-(trifluoromethoxy)benzotrifluoride as the internal standard.





Scheme 5 Proposed mechanism of trifluoromethylation reactions with $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$.

stoichiometry of the overall process and has excellent reactivity, which is in agreement with the literature.¹²

3. Conclusions

In summary, we developed a new trifluoromethylating reagent $\text{Cu}(\text{O}_2\text{CCF}_2\text{SO}_2\text{F})_2$, which efficiently trifluoromethylates various haloarenes under mild conditions. It is a blue solid and can be conveniently prepared from inexpensive starting materials on a large scale. Its decomposition in DMF at room temperature readily affords highly active CuCF_3 species, and the corresponding trifluoromethylation reactions of various haloarenes proceeded smoothly and efficiently at room temperature in good to excellent yields with good functional group compatibility. Moreover, there is no need for an added ligand, which is in contrast with the vast majority of previously reported copper-mediated trifluoromethylation reactions of haloarenes in which the reaction proceeds efficiently only in the presence of a special ligand. Further investigation on the other fluorosulfonyldifluoroacetic acid metal salts is ongoing in our lab, and the results will be reported in due time.

Acknowledgements

The authors gratefully acknowledge the financial support from the National Basic Research Program of China (2012CB821600) and the National Natural Science Foundation of China (21032006, 21302207, 21421002).

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